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| Form PTO-1449 U.S. Department of Commerce (REV. 2-82) Patent and Trademark Office INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary) | Atty. Docket No. A35043-PCT-USA (072944.0155) | U.S. Application No. 10/070,477 International Appln. No. PCT/KR00/00956 |
| | Applicants Kim et al. | |
| | International Filing Date August 25, 2000 | Group To be assigned 1752 |
| | RECEIVED DEC 27 2002 TC 1700 | |

| | Document No. | | | | | | | | Date | Country | Class | Subclass | Translation | |
|-----|--------------|---|---|---|---|---|---|---|------|-----------|-------|----------|-------------|----|
| | | | | | | | | | | | | | Yes | No |
| NEW | | 0 | 5 | 2 | 4 | 9 | 6 | 8 | 3 | 9/28/1993 | JP | | | |
| | | 0 | 5 | 2 | 3 | 2 | 7 | 0 | 6 | 9/10/1993 | JP | | | |
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| | | Ueno et al., 36th Japanese Applied Physics Society Announcement, 1p-k-7, (1989). |
| NEW | | Ito et al., "Applications of Photoinitiators to the Design of Resists for Semiconductor Manufacturing," <i>Polymers in Electronics</i> , American Chemical Society, pp. 11-23 (1984). |

NY02:392102.1 Examiner

Date Considered

2/14/2004

* Examiner: Initial citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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